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Potential transition and post-transition metal sulfides as efficient electrodes for energy storage applications: review

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Electrochemical energy storage has attracted much attention due to the common recognition of sustainable energy development. Transition metal sulfides and post-transition metal sulfides have been intensively focused on due to their potential as electrode materials for energy storage applications in different types of capacitors such as supercapacitors and pseudocapacitors, which have high power density and long cycle life. Herein, the physicochemical properties of transition and post-transition metal sulfides, their typical synthesis, structural characterization, and electrochemical energy storage applications are reviewed. Various perspectives on the design and fabrication of transition and post-transition metal sulfides-based electrode materials having capacitive applications are discussed. This review further discusses various strategies to develop transition and/or post-transition metal sulfide heterostructured electrode-based self-powered photocapacitors with high energy storage efficiencies.

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1. Introduction

Solar energy is one of the well-known abundant energy sources for the development of clean energy technology to meet the future global energy demand. Its development and the respective technological enhancement are crucial to address the

emerging environmental problems associated with the current use of fossil fuels^{1–3} as the proposed energy conservation/storage devices shall be cost-effective, and more reliable with integrated generation of sources and reduced environmental impacts.^{4–8} Moreover, an improved energy storage system is essential for the efficient utilization of solar, hydro, and wind energies.^{9–11} Such energy storage devices could be used in various applications with specific requirements. Parameters such as energy efficiency, power density, response time, cost with economic scale, and lifetime determine the most suitable type of device for an application.¹²

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Commonly, the produced energy can be stored by two different approaches using batteries and capacitors.^{13,14} Batteries convert and store the electrical energy as chemical energy; however, capacitors store the electrical energy as received. The power of a battery is controlled by an electrochemical process.¹⁵⁻¹⁷ Further, the limited lifetime, power density, weak self-discharge, and use of hazardous chemicals are considered major drawbacks of batteries.¹⁸⁻²⁰ Capacitors can be categorized into conventional capacitors, supercapacitors, and photocapacitors based on their purposes/properties. Conventional capacitors can only store very limited energy.^{21,22} However, supercapacitors provide high levels of electrical power and possess a long operational lifetime.²³⁻²⁹ The above capacitors are mostly used to provide short bursts of power in buses and cranes, and hold much promise for electric vehicles and the green grid. Besides, the research on self-powered photocapacitors is of much interest in current trends due to their free energy conversion from the sun and its self-charging properties.^{11,30-35}



Akila Yuvapragasam received her PhD degree in the field of solar cells from Anna University, India in 2017. She has done her post-doctoral fellowship in the field of hybridizing DSSC and supercapacitors. Her research focus is towards solar energy-based supercapacitors and photocapacitors.

2. Photocapacitors

For the sake of completeness, we choose to explain the fundamentals of photocapacitors, which is quite a new thematic area. The good growth of research on photocapacitors aims at the future of replacing batteries with self-charged solar photocapacitors in many smart electronic devices. Photocapacitors can harvest solar energy and store it in the form of electrical energy, and are expected to solve the problem of the unstable power output of solar cells under intermittent sunlight. These photocapacitor architectures mainly belong to the integrated structures of solar cells with supercapacitors and/or heterostructured photoactive electrodes with energy storing materials. The first photocapacitor architecture with a specific capacitance of 0.69 F cm^{-2} was reported in 2004 by integrating dye sensitized solar cell with supercapacitor structures. This sandwich-type electrochemical device consisted of a photoelectrode, a redox-free liquid electrolyte, and a counter electrode. The photoelectrode consisted of dye-adsorbed semiconductive nanoparticles and a porous layer of activated carbon, whereas



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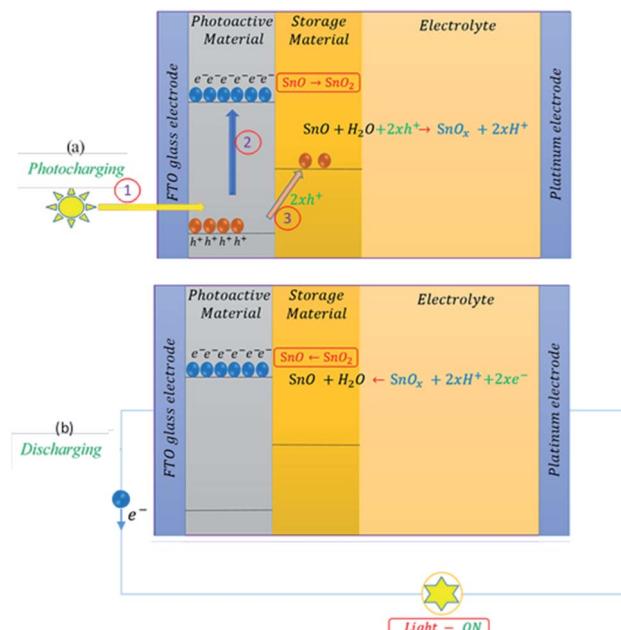


Fig. 1 Working mechanism of a self-powered photocapacitor representing the photocharging process (a) and discharging process (b).

the counter electrode also contained a porous activated carbon layer.³⁰ Thereafter, several research works were reported with integrated architectures.^{36–38} However, the heterostructured photocapacitors are of great interest due to the direct contact between the photoactive and storage materials, making the working electrode itself a light absorber and an energy storage device through an oxidation process. This heterostructured photocapacitor possesses the unique synergistic coupling of photoactive materials and a transition metal sulfide to drive the transition metal oxide derived from its sulfide to act as a capacitive platform *via* redox pseudocapacitance under illumination.

Fig. 1 represents the working mechanism of a heterostructured photocapacitor. Further, Fig. 1a depicts the



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photocharging process, which is mediated by three steps. The electrons in the valence band of a semi-conducting photoactive material absorb solar energy (in step 1) and get excited to the conduction band by leaving positive holes behind (in step 2). Simultaneously, these positive holes are captured (in step 3) by the storage material through an oxidation process; thus, the system gets charged. These charged particles, positive holes and negative electrons, are free charge carriers that can mediate electrical current flow through the device when it is connected to a circuit; thus, the system gets discharged, as shown in Fig. 1b.^{39,40}

In the past few years, transition metal sulfide-based nanomaterials have been extensively studied in supercapacitors,^{41–43} solar cells,^{44,45} hydrogen production,⁴⁶ lithium-ion batteries,⁴⁷ and catalytic^{48,49} applications. Furthermore, transition and post-transition metal sulfides (TMSs) have attracted attention due to their potential as pseudocapacitive materials for capacitors owing to their high specific capacitance, low cost, large global abundance,^{50–54} greater conductivity than their oxide and hydroxide counterparts,^{55,56} and rich redox reactions. In this scenario, a promising $\text{BiVO}_4\text{-PbO}_x$ heterostructured photocapacitive system was reported with a specific capacitance of 6 mF cm^{-2} at a high open circuit potential of 1.5 V vs. reversible hydrogen electrode (RHE). Here, BiVO_4 and PbO_x nanoparticles were employed as photoactive and capacitive layers, respectively. The PbO_x structure was derived from the controlled oxidation of colloidal PbS quantum dots.⁵⁷ However, the toxicity of PbS is of concern; research studies are currently focusing on replacing PbS with non-toxic materials. Recently, a novel heterostructured system with carbon sheet/ $\text{Ag}_2\text{MoO}_4\text{-SnS/Pt}$ was reported with a specific capacitance of 340 F g^{-1} and an open circuit potential of 1.25 V vs. Ag/AgCl electrode. Here, the Ag_2MoO_4 and SnO nanoparticles served as photoactive and capacitive layers, respectively.⁵⁸ The SnO nanoparticles were derived from the controlled oxidation of spherical SnS nanoparticles. The high capacitance is attributed to the large conductive surface and high conductivity of the $\text{Ag}_2\text{MoO}_4\text{-SnS}$ film. The above reported studies with PbS and SnS metal sulphides evidence the energy storage ability in heterostructured photocapacitors. Even though only two of the above papers were published with these types of heterostructured photocapacitors, other transition and post-transition metal sulfides also have potential to be used in these photocapacitors. Therefore, this article reviews the latest advances in transition and post-transition metal sulfides-based capacitors, focusing on their synthesis, characterization, and electrochemical energy storage behaviors. This review will be useful for building research in the field of photocapacitors. The schematic diagram for the outlook on photocapacitors from supercapacitors is shown in Fig. 2.

3. Synthesis of transition and post-transition metal-sulfides

Transition and post-transition metal sulfides have been synthesized by various chemical methods such as solvothermal

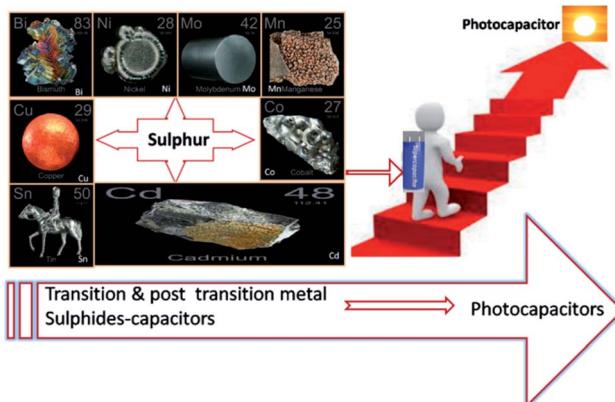


Fig. 2 Outlook for photocapacitors from supercapacitors.

(ST), hydrothermal (HT), electrodeposition (ED), chemical bath deposition (CBD), microwave-assisted synthesis (MWA), wet chemical synthesis, hot injection method, successive ionic layer adsorption and reaction (SILAR), sulfurization, and chemical vapor deposition (CVD). This review mainly focuses on solvothermal, hydrothermal, electrodeposition, chemical bath deposition, microwave-assisted synthesis, wet chemical synthesis, and hot injection methods.

Table 1 summarizes various methods for synthesizing transition and post-transition metal sulfides based on bismuth (Bi), copper (Cu), cobalt (Co), cadmium (Cd), manganese (Mn), tin (Sn), molybdenum (Mo), and nickel (Ni).

4. Structural characterization of transition and post-transition metal-sulfides

X-Ray Diffraction (XRD), Scanning Electron Microscopy (SEM), and X-ray Photoelectron Spectroscopy (XPS) are the important characterization techniques that have widely been used to characterize nanomaterials referred to in Table 1, and are discussed in this section.

4.1. Powder X-ray diffraction (XRD)

This technique is used to study the crystalline nature (phase and crystal size) of nanomaterials. Fig. 3 illustrates the XRD patterns of Bi_2S_3 obtained using different solvent mixtures including water. In all the XRD patterns of Bi_2S_3 samples shown in Fig. 3, the diffraction peaks are observed at 2θ values of 15.65° , 17.55° , 22.35° , 23.70° , 25.20° , 27.35° , 28.60° , 31.80° , 33.00° , 33.90° , 35.60° , 39.00° , 40.10° , 45.60° , 46.55° , 52.75° , 59.20° , 62.60° , 65.05° , and 69.60° . These peaks can be ascribed to the reflections due to (200), (120), (220), (101), (310), (130), (211), (221), (410), (311), (240), (041), (430), (440), (501), (312), (640), (152), (721), and (651) planes of the orthorhombic phase of Bi_2S_3 . The intensity of the peaks varies with different solvent systems. The most crystalline Bi_2S_3 was obtained in the butyldiglycol/water (BG/W) system among all the solvent systems studied.⁵⁹

Peng *et al.* have reported the preparation of CuS using polypyrrole (PPy). Fig. 4 represents the XRD patterns of the as-prepared CuS, PPy, and CuS@PPy composite. All the indexed peaks can be assigned to CuS, which confirms the crystalline structure of CuS with a hexagonal phase.⁶⁴

Chen *et al.* reported the XRD patterns of the reduced graphene oxide on Ni foam (rGONF)/ CoS_2 nanocomposite and bare CoS_2 nanoparticles, as shown in Fig. 5. The diffraction peaks at 27.9° , 32.3° , 36.2° , 39.8° , 46.3° , 54.9° , 57.6° , 60.2° , and 62.7° can be indexed to (111), (200), (210), (211), (220), (311), (222), (023), and (321) planes of CoS_2 . Besides, some other diffraction peaks were assigned to the (111), (311), (222), (511), and (440) planes of Co_9S_8 . However, no peaks of rGO were found in the XRD pattern of the rGONF/ CoS_2 nanocomposite due to the very small quantity of rGO and the strong diffraction density of CoS_2 .⁷⁶

Fig. 6 depicts the XRD patterns of SnS thin films at different reaction times of 120 (TS1), 240 (TS2), and 360 (TS3) min. The (013) plane shows a highly intense peak among the (011), (012), (102), (110), (013), (104), (022), and (115) crystalline planes, which were well matched with JCPDS card no. 00-001-0984. It was found that the detected peak positions and crystal planes belong to the formation of the orthorhombic structure of the prepared SnS (O-SnS) thin films. Further, at the reaction time of 240 min, strong diffraction peaks were observed at (013), (104), and (115) planes.⁹⁵

The XRD patterns of self-synthesized MoS_2 samples were studied by Hu *et al.*,⁹⁶ Huang *et al.*,⁹⁷ and Wang *et al.*,⁹⁹ which could be readily indexed to the hexagonal phase of MoS_2 , consistent with the standard powder diffraction file of MoS_2 (JCPDS 37-1492). The four main diffraction peaks at 14.2° , 32.5° , 35.8° , and 55.4° correspond to the (002), (100), (102), and (106) planes of MoS_2 , which match well with the JCPDS card no. 75-1539.

Fig. 7 represents the XRD pattern of NiS thin film on titanium (Ti) foil substrate synthesized by the CBD method.¹¹⁴ The well-defined diffraction peaks of the as-synthesized NiS are clear evidence of its polycrystalline nature. Moreover, the diffraction peaks at 29.90° , 34.22° , and 45.3° correspond to (100), (101), and (102) planes, respectively, which shows a perfect match with the JCPDS card no. 02-1273 of NiS. The XRD peaks of Ti foil substrate are labeled with a star (*) in Fig. 6, and the average crystallite size calculated along the highly preferred (102) plane using the well-known Scherrer's relation [$D = 0.9\lambda/\beta \cos \theta$] is 19 nm.

Xu *et al.*⁹¹ reported the synthesis of CdS powder by CBD, and its XRD pattern is displayed in Fig. 8. The XRD pattern well matches with the standard cubic CdS (JCPDS card no. 75-1546). The observed diffraction peaks at 2θ of 26.5° , 43.9° , 52.1° , 70.5° , 80.8° , and 86.9° correspond to the planes of (111), (220), (311), (331), (422), and (511), respectively. The lattice constants were calculated to be $a = b = c = 0.5822$ nm for the sample and compared with the standard values of CdS ($a = b = c = 0.5820$ nm). According to Scherrer's relationship, the average crystallite size of CdS was calculated to be 17 nm.

The XRD patterns of the GO, rGO, pure γ -MnS, and γ -MnS/rGO composite, synthesized by Zhang *et al.* through the hydrothermal method, are shown in Fig. 9. The diffraction



Table 1 Synthesis of transition and post-transition metal sulfides reported in the literature

| | Material | Method | Precursors | Solvent | Conditions | Morphology | Ref. |
|--|--|------------------------|--|--|-----------------------|--|-----------|
| 1 | Bi ₂ S ₃ | ST | Bi(NO ₃) ₃ ·5H ₂ O and C ₂ H ₅ NS | Water, ethylene glycol and butyldiglycol | 24 h at 150 °C | Sphere-like Bi ₂ S ₃ nanoparticles | 59 |
| | Bi ₂ S ₃ -rGO | HT | GO, Bi(NO ₃) ₃ ·5H ₂ O, and C ₂ H ₅ NS | Water | 8 h at 160 °C | Bi ₂ S ₃ nanorods on rGO nanosheets | 60 |
| | Bi ₂ S ₃ | | Bi(NO ₃) ₃ ·5H ₂ O and CH ₄ N ₂ S | Ethylene glycol | 10 h at 140 °C | Nanorods | 61 |
| 2 | Bi ₂ S ₃ /graphene | Wet chemical synthesis | GO, BiCl ₃ , and CTAB | Dimethylformamide (DMF) | 3 h at 200 °C | Nanorods | 62 |
| | CuS | ST | Cu(NO ₃) ₂ ·3H ₂ O and sulfur | Ethylene glycol | 24 h at 150 °C | Nanosheets | 63 |
| Polyppyrrole (PPy), copper nitrate hydrate, and CH ₄ N ₂ S | | | PPy, copper nitrate hydrate, and CH ₄ N ₂ S | Glycol | 24 h at 150 °C | Microspheres | 64 |
| 3 | CuS/MWCNT | HT | [Bmim] ₂ Cu ₂ Cl ₆ and CH ₄ N ₂ S | Absolute ethanol | 20 h at 100 °C | 3D hierarchical microspheres | 65 |
| | CuS | | MWCNT, Cu(NO ₃) ₂ ·3H ₂ O, and CH ₄ N ₂ S | Ethylene glycol | 72 h at 180 °C | Nanosheets | 66 |
| | CuS/Ni foam | | Cu(CH ₃ COO) ₂ ·H ₂ O, CH ₄ N ₂ S, CTAB, and NaOH | Double-distilled (DD) water | 20 h at 130 °C | Granular nanostructures | 67 |
| CuS thin films | | | CuCl ₂ ·2H ₂ O, sulfur powder, and Cu powder | Ethanol | 12 h at 80 °C | Nanosheets | 68 |
| CuS/CCs (CSCCs) | | | CuSO ₄ ·5H ₂ O and C ₂ H ₅ NS | Deionized water (DI water) | 50 min at 70 °C | Flower-like morphology | 69 |
| 3 | Co _{1-x} S | ST | CuSO ₄ ·5H ₂ O and CH ₄ N ₂ S | Ethylene glycol | 4 h at 180 °C | 3D flower-like microspheres made up of nanosheets | 70 |
| | CoS _{1.097} | | Co(CH ₃ COO) ₂ ·4H ₂ O and C ₃ H ₇ NO ₂ S | Diethanolamine | 12 h at 200 °C | Flower-like architected nanosheets | 71 |
| | CoS ₂ | | CoCl ₂ ·6H ₂ O and C ₃ H ₇ NO ₂ S | Ethylene glycol | 18 h at 180 °C | Nanotubes | 72 |
| CoS ₂ -rGO | | | Co(CH ₃ COO) ₂ ·4H ₂ O and CS ₂ | Ethylenediamine | 18 h at 200 °C | Yolk-shell and double-shell hollow structures | 73 |
| CoS ₂ | | HT | Co ₂ O ₃ ·6H ₂ O and Na ₂ S ₂ O ₃ | DI water and ethylene glycol | 9 h at 180 °C | Co ₂ S ₂ nanoparticles on RGO nanosheets | 74 |
| rGONF/CoS ₂ | | | CoCl ₂ ·6H ₂ O, sodium citrate, and C ₂ H ₅ NS | DI water and ethanol | 0.5–9 h at 160–200 °C | 3D hollow CoS ₂ cubic structures | 75 |
| CCS/CoS ₂ | | | GO, thiourea, and sulfur powder | Ethanol | 10 h at 200 °C | — | 76 |
| CoS ₂ /MWCNT | | | MWCNT, Co(NO ₃) ₂ ·6H ₂ O, and C ₃ H ₇ NO ₂ S | DI water | 18 h, 150 °C | Nanowires | 77 and 78 |
| Co ₃ S ₈ /3DG | | | Glucose, graphene, CoCl ₂ , and CH ₄ N ₂ S | Ethanol and DI water | 12 h at 180 °C | Nanoparticles | 80 |
| Co ₃ S ₄ /rGO | | | GO, CoCl ₂ ·6H ₂ O, CH ₄ N ₂ O, and Na ₂ S | DI water | 8 h at 120 °C | Nanoflakes | 81 |

Table 1 (Contd.)

| Material | Method | Precursors | Solvent | Conditions | Morphology | Ref. | |
|---|---|---|---|---|--|---|-------------------|
| Co ₃ S ₄ /NF CoS | | Co ₃ O ₄ and CH ₃ CSNH ₂ CoCl ₂ ·6H ₂ O, urea, and Na ₂ S·9H ₂ O | DI water DI water | 0.5–14 h at 120 °C 8 h at 180 °C | Nanosheets Nanotubes | 82 83 | |
| CoS/NF CoS/ERG/Ni foam CoS/INF | ED CBD | CoCl ₂ ·6H ₂ O, glycerol, and C ₂ H ₅ NS CoCl ₂ ·6H ₂ O and CH ₄ N ₂ S CoCl ₂ ·6H ₂ O and CH ₄ N ₂ S | Isopropanol and ethanol NH ₄ OH (aq) HCl (aq) Water/ethanol | 5 h at 120 °C — 180 s 4 h at 90 °C | Hierarchical porous nanospheres Nanosheets Nanoflakes and tapioca sago like nanoparticles | 84 85 86 50 | |
| CoS/NF | MWA | CoCl ₂ ·6H ₂ O, C ₆ H ₈ O ₇ , and C ₂ H ₅ NS Co ₂ (CH ₃ COO) ₂ ·4H ₂ O and C ₂ H ₅ NS | Ethylene glycol DI water | 5 min at 700 W — | 3D flower-like hierachitecture — | 87 88 | |
| CoS _x | | Co ₂ (CH ₃ COO) ₂ and Na ₂ S·9H ₂ O | Methanol and acetone DI water | 5 min at 120 °C — | Hollow nanoprisms — | 89 | |
| CoS | | C ₉ H ₁₈ N ₂ O ₂ S ₂ and CoCl ₂ ·6H ₂ O | DI water | 2 h at 200 and 260 °C 1 h at 80 °C | Nanoplatelets Nanoparticles | 90 91 | |
| CdS/Ni foam | HT | Cd(CH ₃ COO) ₂ ·2H ₂ O and CH ₄ N ₂ S | DI water | 12 h at 180 °C 24 h at 200 °C | Nanorods Leaf-like nanosheet | 92 93 | |
| 5 | γ-MnS/rGO m-SnS ₂ | GO, MnCl ₂ , and Na ₂ S Na ₂ MoO ₄ , SnCl ₄ ·5H ₂ O, and C ₃ H ₇ NO ₂ S | DI water DI water | 2–6 h at 343 K 24 h at 200 °C 48 h at 180 °C | Nanoflower-like structures — Nanosheet-like structures | 94 and 95 96 97 | |
| 6 | O-SnS C/MoS ₂ MoS ₂ | CBD HT | SnCl ₂ and Na ₂ S ₂ O ₃ Glucose and (NH ₄) ₂ MoS ₄ Na ₂ MoO ₄ ·2H ₂ O and C ₃ H ₇ NO ₂ S (NH ₄) ₂ MoO ₄ and CH ₄ N ₂ S (NH ₄) ₆ Mo ₇ O ₂₄ ·4H ₂ O and CH ₄ N ₂ S Na ₂ MoO ₄ ·2H ₂ O and CH ₄ N ₂ S | Double distilled water DI water DI water DI water DI water DI water — | 15 h at 150 °C 8–24 h at 200 °C 1–8 h at 200 °C 24 h at 200 °C 24 h at 200 °C | Sphere-like nanostructures 3D flower-like microspheres composed of nanosheets Nanosheets | 98 99 100 |
| 7 | | Na ₂ MoO ₄ ·2H ₂ O and H ₂ NCSNH ₂ (NH ₄) ₆ Mo ₇ O ₂₄ and SC(NH ₂) ₂ | DI water | 24 h at 210 °C | Sponge Flower-like mesoporous structures | 101 102 | |
| 8 | MoS ₂ /Mo foil | CVD and ED | Mo foil and sulfur powder | Oxalic acid, Na ₂ SO ₄ , and NaF DI water | 0.5–2 h at 200–300 °C 16 h at 120 °C | Sponge-like structures 3D nanosheets | 103 104 |
| 9 | Ni ₃ S ₂ | HT | Ni(NO ₃) ₂ 6H ₂ O and CH ₄ N ₂ S Ni foam and CH ₄ N ₂ S Ni foam and C ₂ H ₅ NS | DI water and ethanol DI water and ethanol | 8 h at 115, 140, 165 °C 6 h at 120, 150, 180 °C 2–8 h at 120 °C | Nanosheets and nanorods 3D hierachical dendrites | 105 106 107 |



Table 1 (Contd.)

| Material | Method | Precursors | Solvent | Conditions | Morphology | Ref. |
|---|--------|--|----------------------------------|---|---|-------------------|
| CNT@Ni ₃ S ₂ NiS/C-dot | | CNTs, Ni(NO ₃) ₂ , and Na ₂ S Lemon juice, NiSO ₄ , and CH ₄ N ₂ S C ₄ H ₁₄ NiO ₈ and CH ₄ N ₂ S | DI water and ethanol DI water | 12 h at 160 °C 24 h at 200 °C | Nanosheets Hierarchical flower-like nanostructure Hollow spheres | 108 109 110 |
| α-NiS β-NiS NiS | | C ₄ H ₁₄ NiO ₈ and CH ₄ N ₂ S | DI water | 12 h at 160 °C 12 h at 200 °C 6 h at 100 °C | Hollow frame-like particles constructed with nanocubes Nanoflakes | 111 |
| Ni ₃ S ₂ /NF Nickel sulfide/ERGO | ED | Ni(NO ₃) ₂ , Na ₃ C ₆ H ₅ O ₇ , C ₆ N ₈ K ₃ Co, and Na ₂ S NiCl ₂ ·6H ₂ O and CH ₄ N ₂ S Graphite, NiCl ₂ ·6H ₂ O, and CH ₄ N ₂ S | DI water DI water | — | — | 112 113 |
| NiS/Ti foil | CBD | Ni(NO ₃) ₂ ·6H ₂ O and CH ₄ N ₂ S | Ethanol | 4 h at 70 °C | Nanorods/nanoplates | 114 |
| NiS ₂ /NF | MWA | Ni(NO ₃) ₂ , CH ₄ N ₂ S, and polyvinylpyrrolidone K-30 (PVP) | DI water | 2–4 h at 150 °C | Nanocubes, nanospheres, and nanoparticles | 115 |

planes of γ -MnS are (100), (002), (101), (102), (110), (103), (200), (112), (201), (202), (203), (210), and (211), which match well with its 2θ values (JCPDS no. 40-1289). The synthesized γ -MnS is fairly pure because the XRD spectrum does not show any peaks that correspond to other materials. However, the diffraction peaks found for the γ -MnS/rGO composite are inconsistent with that of pure γ -MnS. Further, the diffraction peak position of 25° for rGO is not clearly noted due to the low stacking degree and fairly even dispersion of rGO in the as-synthesized composite.⁹²

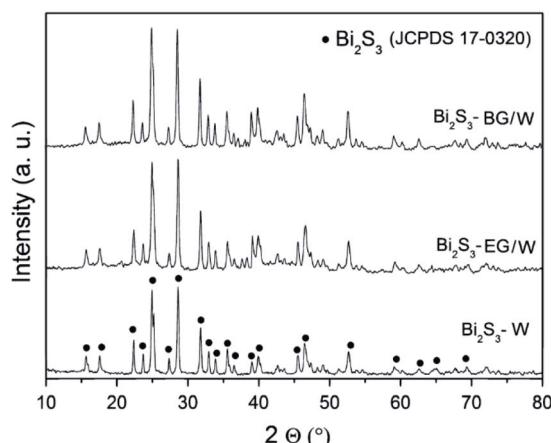
4.2. Field emission scanning electron microscopy (FESEM)

FESEM is used to understand the surface morphologies of the transition and post-transition metal sulfides. Fig. 10a–c depicts the surface morphologies of the samples of orthorhombic SnS (O-SnS) thin films prepared at TS1, TS2, and TS3 (120, 240, and 360 min). The FESEM images of all the films show that O-SnS nanostructures have been homogeneously grown throughout the surface of the film. It can be seen that the surface morphology differs with the deposition time as nanoflakes at TS1, nanoflowers at TS2, and nanogranules at TS3.^{94,95}

Fig. 11 shows the surface morphologies of (a) GO, (b) rGO, (c) pure γ -MnS, and (d) γ -MnS/rGO-60 composite. It was observed that many wrinkles of rGO sheets were coated on the γ -MnS surfaces and interlaced with each other. Moreover, the presence of rGO impacts the morphology of MnS, *i.e.*, the γ -MnS/rGO-60 composite shows a nanoparticle-assembled rod structure as a result of rGO coated on MnS nanoparticles restraining the aggregation and limiting the rod growth.⁹²

Fig. 12a depicts the low-magnification SEM image of CdS spheres directly grown on Ni foam through the hydrothermal method. Electrolyte penetration is facilitated with the CdS/Ni foam, which possesses a 3D grid structure with hierarchical macroporosity. Fig. 12b and c show the higher magnification SEM images of CdS/Ni foam electrode, which reveals that the average diameter of CdS sphere is about 2 μ m. As seen in the further enlarged Fig. 12d, the CdS microsphere is tremelloid.⁹¹

The FESEM surface morphology of the NiS thin film deposited on Ti foil by Gaikar *et al.* is shown in Fig. 13. The NiS film possesses a uniformly distributed network of nanorods over the

Fig. 3 XRD patterns of Bi₂S₃ samples in different solvent systems.⁵⁹

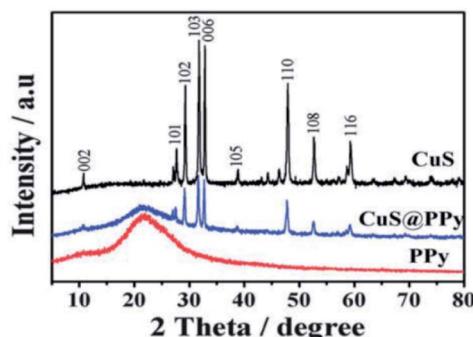


Fig. 4 XRD patterns of CuS, PPy, and CuS@PPy composite.⁶⁴

Ti foil substrate with several air voids. The diffusion of electroactive species is made effective due to the open vacant space between the nanorods/nanoplates during the intercalation/de-intercalation process. Hence, the shrinkage of internal resistance of the nanomaterial takes place, which enhances its capacitive performance.¹¹⁴

Fig. 14 shows the typical SEM images of pure Bi_2S_3 and Bi_2S_3 -graphene (BG) composite. Pure Bi_2S_3 with an irregular rod-like structure and an average size of 40–70 nm can be observed in Fig. 14a. Fig. 14b shows that the rGO sheets in the composite are not perfectly flat and display a crumpled and rippled structure. The individually grown Bi_2S_3 nanorods on rGO ensure that each nanorod participates in the electrochemical process of the energy storage system.⁶²

Fig. 15a represents the NiS_2 nanoparticles with a size of 50 nm, which were obtained after 30 min of microwave irradiation. The NiS_2 nanospheres between the size of 50 and 150 nm were observed after 2 h of microwave irradiation, and are shown in Fig. 15b. Further, 3 h of microwave irradiation produce imperfect NiS_2 nanocubes, as shown in Fig. 15c, while perfect and uniform NiS_2 nanocubes were successfully obtained as shown in Fig. 15d with 4 h of microwave irradiation.¹¹⁵

Fig. 16 shows a uniformly grown thin film of CoS with high density on the Ni foam, forming a 3D hierarchical structure, as illustrated in the inset of Fig. 16a. In the higher magnification images of Fig. 16b and c, the CoS thin films on the Ni foam

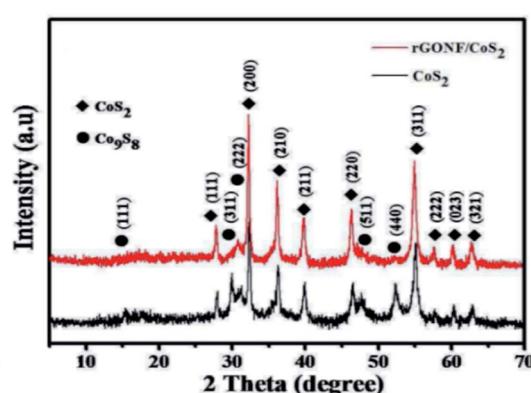


Fig. 5 XRD patterns of the bare CoS_2 nanoparticles and the rGONF/ CoS_2 nanocomposite.⁷⁶

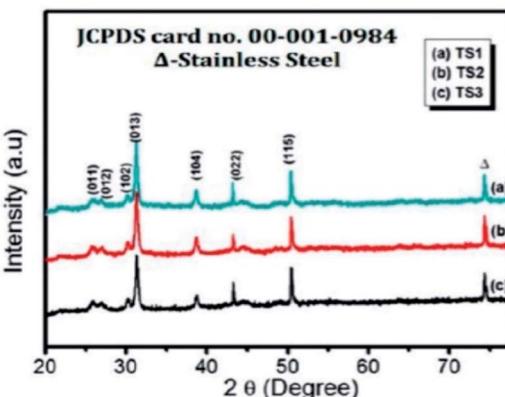


Fig. 6 XRD patterns of SnS thin films at reaction times of 120 (TS1), 240 (TS2), and 360 (TS3) min.⁹⁵

exhibit a characteristic morphology composed of interlaced nanosheets.⁸⁵

The SEM image of CuS in Fig. 17a indicates that the prepared CuS consists of uniform spheres with an average diameter of 1 μm , and these microspheres are composed of several intertwined sheet-like subunits. Fig. 17b and c correspond to the CuS@PPy composite, in which an aggregate of PPy on individual CuS microspheres exhibits a rough surface.⁶⁴

4.3. X-ray photoelectron spectroscopy (XPS)

The exterior and synthetic states of the molecules within the prepared sample were evaluated using XPS. The wide scan XPS spectrum of the orthorhombic SnS (O-SnS) thin film deposited in 240 min is shown in Fig. 18a. Peaks of the spectrum are assigned to Sn $3\text{d}_{3/2}$, Sn $3\text{d}_{5/2}$, S $2\text{p}_{3/2}$, C 1s, and O 1s states. The Sn 3d spectrum, which is shown in Fig. 18c, exhibits two main peaks corresponding to Sn $3\text{d}_{5/2}$ and Sn $3\text{d}_{3/2}$ states that are positioned at 486.5 and 495 eV, respectively. The energy separation among these two peaks is about ~ 8.5 eV, which matches well with the reported value in the literature;¹¹⁶ this designates Sn in the SnS phase and +2 oxidation state. In addition to these main peaks, the S $2\text{p}_{3/2}$ state is observed at 168.6 eV, as shown in Fig. 18b. This confirms the occurrence of the pure O-SnS phase in the film layers.⁹⁵

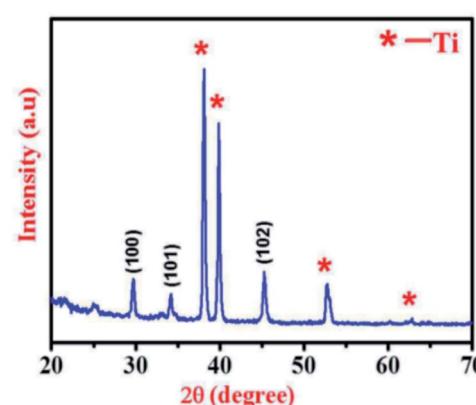


Fig. 7 XRD pattern of NiS thin film on titanium (Ti) foil.¹¹⁴

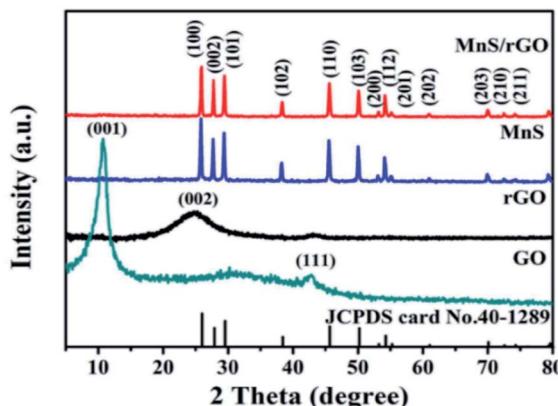
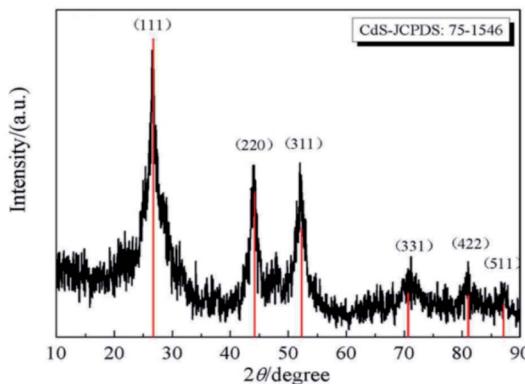
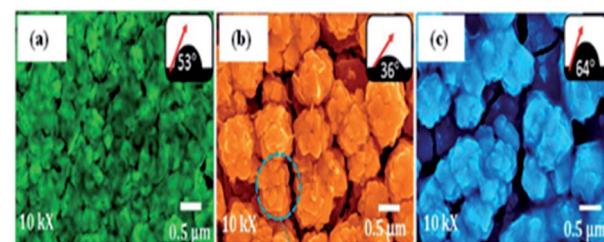
Fig. 8 XRD pattern of CdS powder.⁹¹

Fig. 19 depicts the XPS spectra of CoS-interlaced nanosheets, which were synthesized *via* a facile microwave-assisted (MWA) method.⁸⁷ Fig. 19a shows the Co 2p spectrum, whereas the main peaks located at the lower binding energy value of 777.9 eV and higher binding energies are assigned to Co²⁺ in CoS. Fig. 19b shows that the binding energy value of the S 2p state is about 162.5 eV, which indicates that most of the S species exist as S²⁻ in the product, as reported in the literature.⁸⁵ Moreover, the peak at 168.5 eV represents the O impurity.

Fig. 20 represents the chemical states of Bi₂S₃, which were investigated by high-resolution Bi 4f and S 2p XPS spectra. Fig. 20a depicts the overall spectrum of Bi₂S₃ in water, ethylene glycol/water, and butyl glycol/water. The Bi 4f spectrum of Bi₂S₃-W (water) in Fig. 20b shows two predominant peaks at 158.1 and 163.4 eV, which correspond to the spin states of Bi 4f_{7/2} and Bi 4f_{5/2}, respectively, in Bi₂S₃. The Bi 4f spectra of the other samples show peaks at 158.3 and 163.6 eV for Bi₂S₃-EG/W (ethylene glycol/water) as in Fig. 20c, and peaks at 157.7 and 163 eV for Bi₂S₃-BG/W (butyl glycol/water) as in Fig. 20d. The peak positions in Fig. 19 match well with the binding energy values reported in the literature for Bi³⁺.¹¹⁷ The magnified core-level S 2p spectrum is shown below the Bi 4f region for each Bi₂S₃ sample. The S 2p region consists of two asymmetric peaks. The signal with a higher intensity located at about 162 eV is ascribed to S 2p_{3/2} and the smaller signal at about 160.7 eV is

Fig. 9 XRD patterns of GO, rGO, γ -MnS, and γ -MnS/rGO.⁹²Fig. 10 FESEM images of O-SnS thin films prepared at (a) TS1 (120 min), (b) TS2 (240 min), and (c) TS3 (360 min).^{94,95}

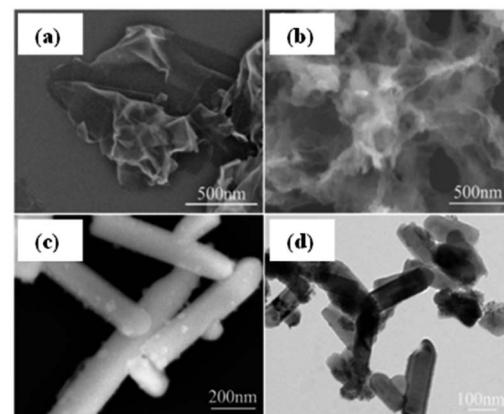
attributed to the spin state of S 2p_{1/2}. The S 2p peaks are at 162 and 160.8 eV for Bi₂S₃-W, 161.6 and 160.5 eV for Bi₂S₃-EG/W, and 162.2 and 161.1 eV for Bi₂S₃-BG/W. The positions of the S 2p_{3/2} and S 2p_{1/2} signals in the S 2p spectra prove that sulfur exists in its S²⁻ valence state.⁵⁹

Xu *et al.*⁹¹ evaluated the valence states of Cd and S in CdS samples using XPS, where CdS was synthesized through the hydrothermal method. The existence of cadmium in its Cd²⁺ state was confirmed by the presence of the two peaks at 405.2 eV for Cd 3d_{5/2} and 412 eV for Cd 3d_{3/2} as shown in Fig. 21a, whereas the S 2p peaks at 161.6 and 162.7 eV are attributed to S 2p_{3/2} and S 2p_{1/2}, respectively, as shown in Fig. 21b.

Yu *et al.* reported the hydrothermally synthesized MoS₂, which consists of Mo 3d_{5/2} and Mo 3d_{3/2} peaks at 228.9 and 232.0 eV, respectively.¹⁰⁰ Further, S 2p exhibits the doublet shape of two peaks, S 2p_{3/2} and S 2p_{1/2}, located at 161.7 and 162.9 eV, respectively. The above observations confirm the +4 and -2 oxidation states for Mo and sulfur in MoS₂, respectively. Likewise, Huang *et al.* reported that the predominant elements in the MoS₂ sample are Mo and S ascribed by XPS and the atomic ratio of Mo to S is about 1 : 2.⁹⁷

5. Energy storage in metal sulfides-based capacitors

The electrochemical performance of various self-synthesized nanomaterials has been determined with the help of

Fig. 11 SEM images of (a) GO, (b) rGO, (c) pure γ -MnS, and (d) γ -MnS/rGO-60 composite.⁹²

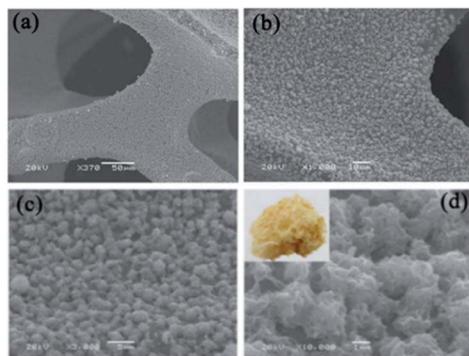


Fig. 12 SEM images of CdS/Ni foam electrode at different magnifications of (a) $\times 370$, (b) $\times 1000$, (c) $\times 3000$ and (d) $\times 10000$.⁹¹

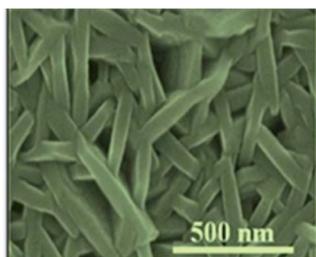


Fig. 13 FESEM image of NiS thin film on Ti foil.¹¹⁴

electrochemical impedance spectroscopy (EIS), cyclic voltammetry (CV), and galvanostatic charge–discharge (GCD) curves. This section mainly focuses on CV and GCD, which explain the energy storage capability of the synthesized nanomaterials in terms of specific capacitance.

5.1. Bismuth sulfide

Bismuth sulfide (Bi_2S_3) is a well-known lamellar structured semiconductor and possesses extraordinary photoconductivity, favorable photovoltaic properties, and low bandgap; it is environment friendly, low cost, and high in abundance.^{60,118,119} The Bi_2S_3 samples can be synthesized by various methods such as solvothermal,⁵⁹ wet chemical,⁶² and hydrothermal,⁶⁰ as reported in Section 2. In the solvothermal method, Miniach *et al.* used different solvent systems to synthesize Bi_2S_3 such as water (Bi_2S_3 –W), ethylene glycol/water (Bi_2S_3 –EG/W), and butyl diglycol/water (Bi_2S_3 –BG/W). Furthermore, the CV parameters of synthesized Bi_2S_3 in each solvent system recorded at scan

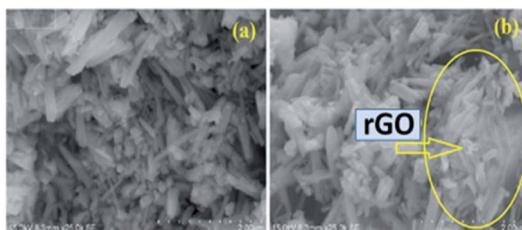


Fig. 14 FESEM images of (a) Bi_2S_3 and (b) BG composite.⁶²

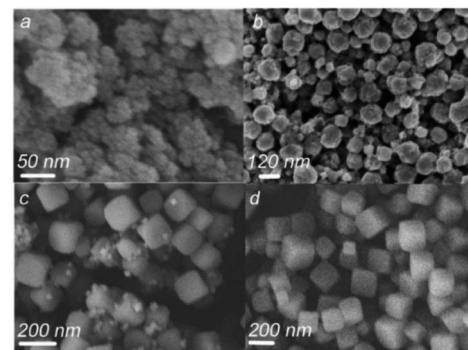


Fig. 15 SEM images of NiS_2 after microwave irradiation for different time durations: (a) 30 min, (b) 2 h, (c) 3 h, and (d) 4 h.¹¹⁵

rates of 1 and 100 mV s^{-1} are shown in Fig. 22a and b, respectively.

As illustrated in the above cyclic voltammograms, the Bi_2S_3 electrode materials were tested in a wide potential range from -0.1 to -0.9 V . The distinct redox peaks ascribed in Fig. 22a at -0.6 and -0.45 V during the anodic and cathodic sweeps represent the pseudocapacitive behavior of Bi_2S_3 , respectively. The redox couple can arise from the change in the bismuth valence state ($\text{Bi}^{3+}/\text{Bi}^0$) or be induced by the frequently reported reversible reaction between Bi_2S_3 and the OH^- ions in the electrolyte.^{61,120} The other redox couple observed in Fig. 22b could be related to the adsorption–desorption of hydrogen in Bi_2S_3 .¹²¹ However, when the scan rate increases to 100 mV s^{-1} , many redox peaks fade, as shown in Fig. 22b. The calculated specific capacitances of Bi_2S_3 –W, Bi_2S_3 –EG/W, and Bi_2S_3 –BG/W from the CV curves, recorded at the scan rate of 1 mV s^{-1} , are found to be 608 , 630 , and 615 F g^{-1} , respectively. Further, Bi_2S_3 –BG/W showed a specific capacitance of 168 F g^{-1} at 100 mV s^{-1} scan rate, which demonstrated its superior capability compared to that of Bi_2S_3 –W (106 F g^{-1}) and Bi_2S_3 –EG/W (118 F g^{-1}).⁵⁹

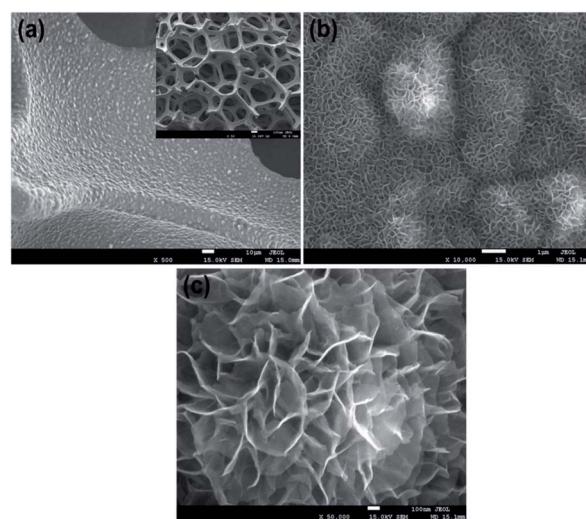


Fig. 16 FESEM images of CoS on Ni foam substrate at (a) low, (b and c) higher magnifications.⁸⁵

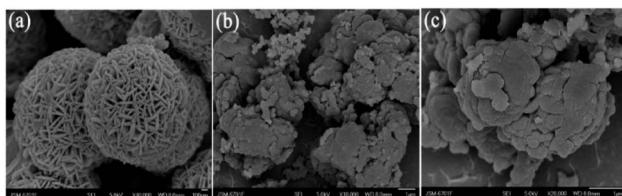


Fig. 17 SEM images of (a) CuS, (b and c) CuS@PPy composite at low and high magnifications.⁶⁴

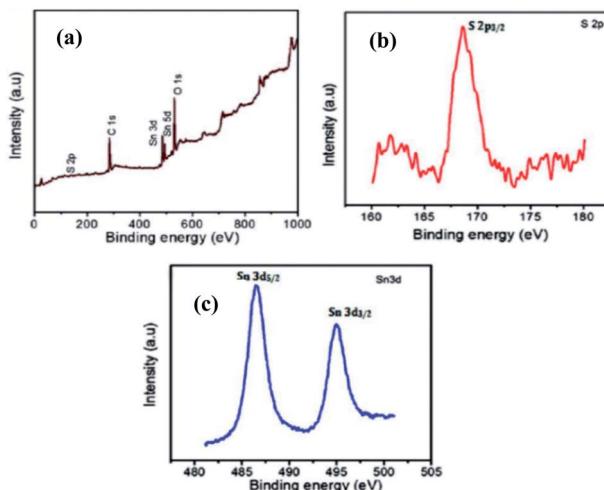


Fig. 18 XPS spectrum of O-SnS thin film (a) survey scan spectrum, (b) S 2p, and (c) Sn 3d core level.⁹⁵

Vadivel *et al.* employed the wet chemical method to synthesize the pure Bi₂S₃ and Bi₂S₃-graphene (BG) electrode materials. Fig. 23a shows the CV curves of the BG composite and pure Bi₂S₃ at the scan rate of 5 mV s⁻¹ in the potential range from -0.2 to -1.0 V. Further, the anodic and cathodic peaks that appeared in the spectrum are due to the oxidation and reduction of OH⁻ ions and Bi₂S₃ electrode material, respectively. When the scan rate increased from 5 to 100 mV s⁻¹ for the BG composite, as shown in Fig. 23b, the shape of the CV curve was maintained by representing an excellent performance of the electrode material and subsequently increased the anodic and cathodic processes. Further, the presence of graphene in the BG composite increased the capacitance value due to its higher conductivity compared to that of Bi₂S₃.⁶²

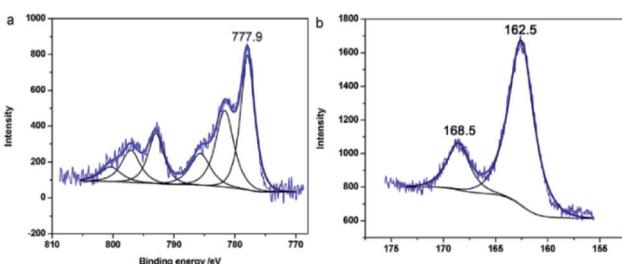


Fig. 19 XPS spectra of (a) Co 2p and (b) S 2p of CoS.⁸⁷

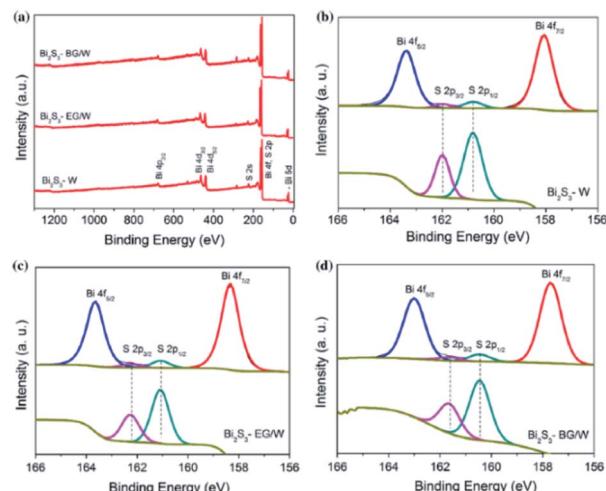


Fig. 20 XPS spectra of Bi₂S₃ (a) survey scan spectrum and high-resolution Bi 4f and S 2p spectra of (b) Bi₂S₃-W, (c) Bi₂S₃-EG/W, and (d) Bi₂S₃-BG/W.⁵⁹

The calculated specific capacitances of Bi₂S₃ and BG composite materials from the GCD curves are shown in Fig. 24a and b, respectively, and the values of the BG composite are 290, 282, 187, 182, 126, and 110 F g⁻¹ at different current densities. Moreover, these values are higher than those of pure Bi₂S₃ (191, 140, 108, 107, 80, and 68 F g⁻¹) at similar current densities. The effective incorporation of graphene sheets over Bi₂S₃ nanorods in the BG composite could be the reason behind the improved rate capability. Further, the increased surface area, higher conductive nature, and flexibility of graphene may have influenced the electrochemical performance of the BG composite material.¹²²⁻¹²⁴ Moreover, the rod-like structure of the BG composite could have provided more active sites for the redox process of the active material with greater interfacial contact between the electrode and the electrolyte.^{125,126}

Nie *et al.*⁶⁰ prepared X-Bi₂S₃ (without GO), rGO, and BGNS composites (with GO) using the hydrothermal method. Fig. 25 illustrates the CV and GCD profiles of the above materials. Fig. 25a depicts the typical CV curves of the above products at 5 mV s⁻¹. Further, the CV plots of the BGNS samples expanded along with the decreased additive amounts of GO (BGNS 1, 2, and 3 with 15, 30, and 45 mg of GO, respectively) indicate better capacitance values compared to bare rGO and X-Bi₂S₃. Specific

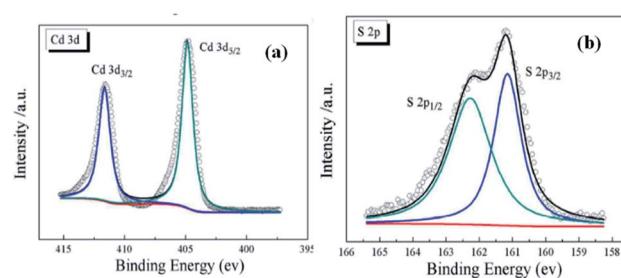


Fig. 21 XPS spectra of (a) Cd 3d and (b) S 2p of CdS.⁹¹

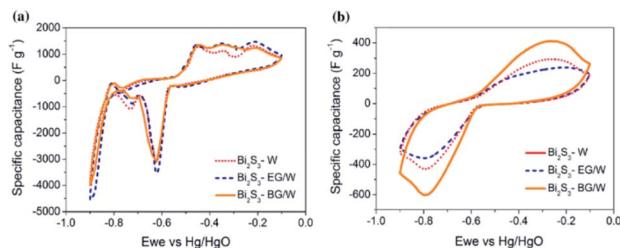


Fig. 22 CV curves of Bi_2S_3 electrodes at (a) 1 mV s^{-1} and (b) 100 mV s^{-1} .⁵⁹

capacitance values were determined from the GCD curves recorded at the current density of 1 A g^{-1} , as shown in Fig. 25b, for BGNS-3 (201 F g^{-1}), BGNS-2 (342 F g^{-1}) and BGNS-1 (396 F g^{-1}); BGNS-1 exhibited the highest capacitance, which was higher compared to the obtained capacitances for rGO (136 F g^{-1}) and X-Bi₂S₃ (60 F g^{-1}).

The increased specific capacitance of the BGNS composite may be attributed to the synergistic effect between Bi_2S_3 and carbon (rGO/GO). It facilitates effective electron transport and faster ion diffusion during the charge–discharge process through the electrolyte when the material employed is an active material for supercapacitor electrodes, thus enforcing the BGNS composite with superior electrochemical performance over bare rGO and pure Bi_2S_3 nanomaterials. Moreover, the contact area enhances with the decrease in the particle size, which could play a significant role in the accessibility of the composite materials to OH^- ions and shorten the ion migration pathway during the charge–discharge process, thus increasing the specific capacitance of the BGNS composite.

5.2. Copper sulfide

Copper sulfide (CuS) has been considered as one of the most promising pseudocapacitor materials due to its excellent metallic properties, high specific capacity, and excellent physical, chemical, structural, and surface properties.^{127–129} CuS has been synthesized by various methods such as solvothermal method, hydrothermal method, CBD, and CVD. Here, we focus on the solvothermal^{63,64} and hydrothermal^{66,69,70} synthesis of CuS only. Huang *et al.* and Peng *et al.* used the solvothermal method to synthesize CuS-based electrode materials. The CV curves of CuS-CTAB (cetyltrimethylammonium bromide), CuS-SDBS (sodium dodecylbenzenesulfonate), and pure CuS in the

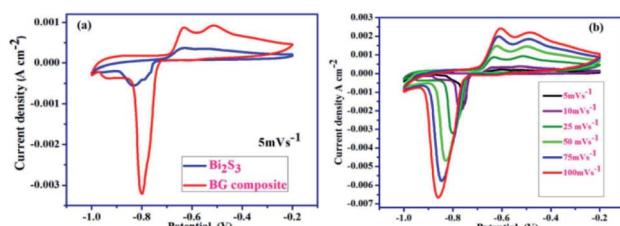


Fig. 23 CV curves of (a) the BG composite and pure Bi_2S_3 at 5 mV s^{-1} and (b) the BG composite at different scan rates.⁶²

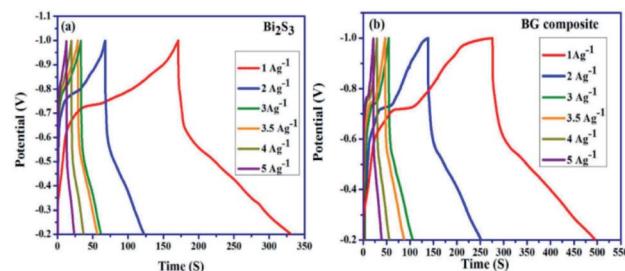


Fig. 24 GCD curves of (a) Bi_2S_3 and (b) BG composite at different current densities.⁶²

potential range from -0.4 to -0.6 V are shown in Fig. 26a. It can be observed that these CV curves deviate from the ideal rectangular shape, signifying the pseudocapacitive behavior. Fig. 26b represents the GCD profiles of the above electrode materials at a current density of 1 A g^{-1} and pure CuS shows the highest specific capacitance of 833.3 F g^{-1} compared to 378.9 F g^{-1} and 232.4 F g^{-1} for CuS-CTAB and CuS-SDBS, respectively. As illustrated by the CV and GCD curves, the CuS electrode possesses higher capacitance than CuS-CTAB and CuS-SDBS electrodes due to the thinner layer of CuS. This thinner layer enables the easier penetration of electrolytes to promote electron and charge transfer.⁶³

Fig. 27a shows the CV curves of solvothermally synthesized CuS, PPy, and CuS@PPy composite at the scan rate of 25 mV s^{-1} with the electrolyte of 1 M KCl . The insertion and expulsion of K^+ ions are indicated in the CV curve of PPy, which possesses a couple of redox peaks.¹²⁶ The CuS electrode presents a pair of redox peaks at about 0.31 and 0.1 V , which are attributed to the CuS/Cu₂S redox transition.¹²⁷ Similarly, the CuS@PPy composite shows another pair of redox peaks at about 0.31 V and 0.05 V . Fig. 27b gives the GCD curves of CuS, PPy, and CuS@PPy composite electrodes with the capacitance values of 212 , 275 , and 427 F g^{-1} , respectively, at 1 A g^{-1} . Besides, the increase in the CuS content in the CuS@PPy composite resulted in an increase in the specific capacitance. Further, the specific capacitance of the CuS@PPy composite is higher compared to both pure CuS and PPy. This is probably due to the presence of CuS, which possesses better conductivity than PPy and also provides a path for the insertion and extraction of K^+ ions within PPy.⁶⁰

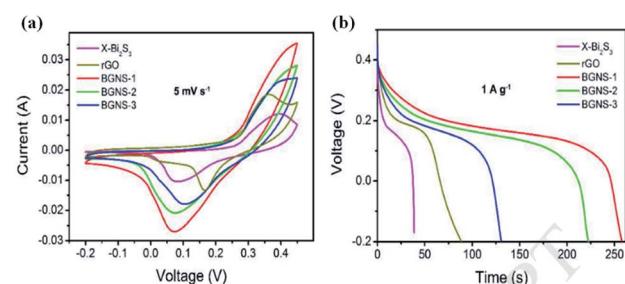


Fig. 25 (a) CV curves at a scan rate of 5 mV s^{-1} and (b) GCD curves at a current density of 1 A g^{-1} .⁶⁰



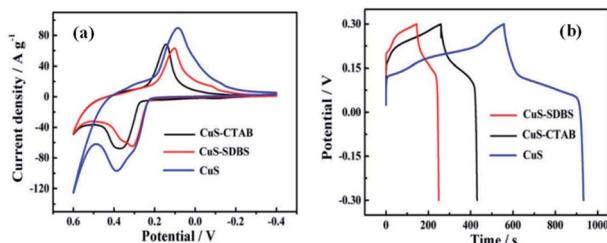


Fig. 26 (a) CV and (b) GCD curves of CuS-CTAB, CuS-SDBS, and CuS electrodes.⁵³

In another study reported by Zhang *et al.*,⁶⁵ the specific capacitance values of CuS microspheres were found to be 237, 216, 204, 195, 187, and 180 F g⁻¹ at different current densities. Further, about 75.9% of the original specific capacitance was retained when the current density increased from 0.5 to 8.0 A g⁻¹. Furthermore, the thin CuS nanosheets significantly shorten the diffusion pathway compared to the thick plate-like structure of CuS. Moreover, CuS nanosheets facilitate higher surface area, which increases the rate of redox reaction due to the presence of a large number of electrochemically active sites.

Huang *et al.*,⁶⁶ Marimuthu *et al.*,⁶⁹ Zhang *et al.*,⁶⁸ and Zhai *et al.*⁷⁰ reported the electrochemical performance of hydrothermally synthesized CuS. As shown in Fig. 28a, the shape of the CV curves clearly exhibits the pseudocapacitive behavior of CuS/MWCNTs, pure CuS, and pure MWCNTs in the potential range from -0.4 to 0.6 V at the scan rate of 50 mV s⁻¹. It is obvious that the CuS/MWCNTs composite electrode possesses higher capacitance than pure electrodes. Fig. 28b shows the GCD curves of CuS, MWCNTs, and CuS-MWCNTs with the specific capacitance values of 925.1, 555.6, and 2831.0 F g⁻¹, respectively, at a current density of 1 A g⁻¹ in 6.0 M KOH electrolyte. This indicates that the specific capacitance of the hybrid material is greatly enhanced due to the interaction between CuS sheets and WMCNTs, which accelerates electrochemical performance as a result of the effective and rapid conduct of charge carriers.⁶⁶

Zhang *et al.* reported that the Ni foam-supported CuS nanowall arrays electrode delivers high specific capacitances of 1124, 1053, 912.5, 864.3, 815.5, and 689.4 F g⁻¹ at current densities of 15, 20, 30, 40, 50, and 80 mA cm⁻², respectively.⁶⁸ In another study, the highest specific capacitance of 298 F g⁻¹ at

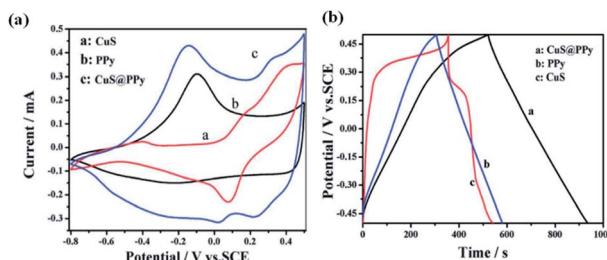


Fig. 27 (a) CV curves and (b) GCD curves of CuS, PPy, and CuS@PPy composite.⁵⁰

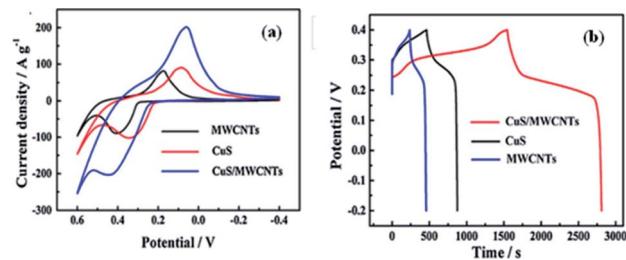


Fig. 28 (a) CV curves at 50 mV s⁻¹ and (b) GCD curves at current density of 1 A g⁻¹ of CuS, MWCNTs, and CuS/MWCNTs composite.⁶⁶

2 A g⁻¹ current density was obtained for CuS nanoparticles prepared with 1 : 2 ratio of copper acetate and thiourea.⁶⁷ However, the hydrolysis of ions and growth of CuS nanoparticles are hindered by the addition of CTAB that induces earlier micellization, which results in the formation of charged micelles on copper sulfide nanoparticles. Moreover, the liberation rate of S²⁻ ions from thiourea has also been influenced by changing the concentration of thiourea in the alkaline precursor solution. The combined effect of thiourea concentration and diverse rate of hydrolysis is positive for assembly and anisotropic growth. The concentration of thiourea greatly affects the physical and electrochemical features of CuS.

In another study, the calculated specific capacitance values of sandwich-type flower-like CuS/carbonized cloth (CSCC) electrodes, prepared at different reaction times such as 3, 4, 5, and 6 h, were found to be 2168, 3468, 3112, and 2876 F cm⁻², respectively, at 4 mA cm⁻², which were higher than the CC electrode with 61 F cm⁻² at the same current density.⁷⁰

5.3. Nickel sulfide

Nickel sulfide belongs to VI-VIII compound semiconductor and has attracted significant attention owing to its high electronic conductivity, low cost, ease of synthesis, low toxicity, and high specific capacitance.¹³⁰⁻¹³² As widely reported, hydrothermal, chemical bath deposition, wet chemical synthesis, and microwave-assisted synthetic methods have been used to synthesize various micro/nanostructures of nickel sulfide electrode materials. Many different phases of nickel sulfide such as NiS, Ni₃S₂, Ni₂S, Ni₃S₄, Ni₇S₆, and Ni₉S₈ have been extensively investigated in recent decades due to their versatile applications in supercapacitors, catalytic hydrogenation, dye-sensitized solar cells, and lithium-ion batteries.

Xiong *et al.*¹⁰⁶ studied the CV of Ni₃S₂ nanorod arrays obtained at various temperatures. The CV curves shown in Fig. 29a exhibit a notable pair of redox peaks in the potential range from -0.2 to 0.7 V. The redox peaks near 0.48 and 0.12 V (vs. Ag/AgCl) can be attributed to the reversible redox reactions of Ni²⁺/Ni³⁺. The specific capacitances of three types of Ni₃S₂ synthesized at different temperatures of 115 °C, 140 °C, and 160 °C at 30 mV s⁻¹ were found to be 420, 464, and 306 F g⁻¹, respectively. The properties of interfacial surface structure and ionic/electronic diffusion of the electrode materials have vital roles in improving the specific capacitance of the supercapacitors. The specific capacitances calculated from the GCD curves shown in



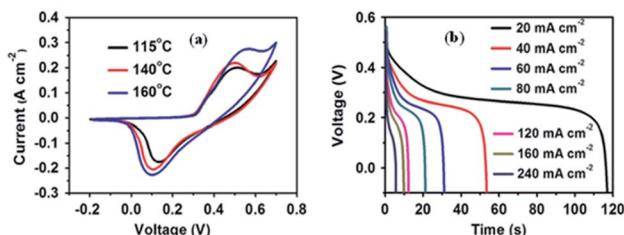


Fig. 29 (a) CV curves of Ni₃S₂ at different temperatures and (b) GCD curves of Ni₃S₂ at different current densities.¹⁰⁶

Fig. 29b revealed the highest specific capacitance of 694 F g⁻¹ at a discharge current density of 20 mA cm⁻² for Ni₃S₂ nanosheet@nanorods, which was formed at 115 °C. Here, the Ni₃S₂ nanorods are well wrapped by Ni₃S₂ nanosheets and possess a highly open structure that offers sufficient space for buffering the volume changes during the charge-discharge process. At the same time, Ni₃S₂ nanosheets largely increase the contact area between the electrolyte and active materials, and greatly facilitate ion and electron diffusion.

The hydrothermally synthesized 3D hierarchical nanostructures of Ni₃S₂ on Ni foam were studied as a supercapacitor electrode.¹³³ These 3D nanostructures exhibit a significant increase in the active material availability for electrochemical performance. The 3D hierarchical nanostructures of Ni₃S₂ showed a high specific capacitance of 710.4 F g⁻¹ at the current density of 2 A g⁻¹. Later, Huo *et al.* prepared the 3D Ni₃S₂ nanosheets array on Ni foam electrode, which exhibited a high specific capacitance of 1370.4 F g⁻¹ at the current density of 2 A g⁻¹. The good performance of Ni₃S₂ nanosheets can be ascribed to the unique porous and open structure of the Ni₃S₂ nanosheets that facilitate the penetration of the electrolyte into the inner part and shorten the ionic diffusion path, hence improving the dynamic performance. Moreover, the open space within the Ni₃S₂ nanosheets can store a large number of ions, which ensures that sufficient faradaic reactions can take place for energy storage.¹³³

From the CV measurements of pristine NiS and NiS/C-dots composite carried out in 2 M KOH electrolyte solution, it can be seen that both materials exhibit pseudocapacitive nature with the appearance of an oxidation peak and a corresponding reduction peak in their CV profiles. The NiS/C-dots composite material possesses significantly high current density compared to the pristine NiS due to the better charge transport property of the composite material compared to the pristine NiS material (larger peak separation of 0.29 V was observed for pristine NiS). The maximum specific capacitance of 650 F g⁻¹ was obtained for the NiS/C-dots composite, which is larger than that of pristine NiS (480 F g⁻¹) at 10 mV s⁻¹ scan rate. The transport of charge deep inside the matrix is quite fast in NiS/C-dots composite electrode material due to the incorporation of highly conducting carbon dots; therefore, the specific capacitance of the said material is improved.¹⁰⁹

Wei *et al.* performed CV measurements on hollow α -NiS and β -NiS materials in 3.0 M KOH electrolyte by varying the scan

rates from 5 to 100 mV s⁻¹. The shape of these curves indicates the pseudocapacitive behavior. The specific capacitances derived from the GCD curves are 562.3 and 501.5 F g⁻¹ for α -NiS and β -NiS, respectively, at 0.6 A g⁻¹. At a higher current density of 6.0 A g⁻¹, the specific capacitance of α -NiS remained at 201.9 F g⁻¹, while that of β -NiS hollow sphere electrode reduced to 169.1 F g⁻¹. Hence, α -NiS hollow sphere electrode is significantly better than the β -NiS electrode in terms of the specific capacitance.¹¹⁰

Shu-Wei Chou and Jeng-Yu synthesized flaky nickel sulfide (Ni₃S₂) nanostructure on Ni foam by the ED method, which showed a high specific capacitance of 717 F g⁻¹ at 2 A g⁻¹ in 1 M KOH electrolyte solution. The CV shape of the Ni₃S₂ flaky electrode differs from the rectangular CV shape of an ideal electric double-layer capacitor and reveals diverse pseudocapacitive characteristics.¹¹² Further, a nickel sulfide/electrochemically reduced graphene oxide (erGO) nanocomposite prepared by the ED method has been reported by Liu *et al.* The CV of this nanocomposite displays distinct pseudocapacitive characteristics, which is quite different from the rectangular CV shape of the erGO-based supercapacitor. This suggests that the total capacitance mainly depends on the nickel sulfide rather than erGO. When compared with sole nickel sulfides,¹³⁴ the nickel sulfide/erGO nanocomposite shows a higher specific capacitance of 1392.2 F g⁻¹ at a current density of 2 A g⁻¹.¹¹³

Pang *et al.* synthesized NiS₂ nanocubes, nanospheres, and nanoparticles by microwave-assisted synthesis. The CV curve of NiS₂ nanocubes electrode in 3.0 M KOH electrolyte solution shows a broad redox peak due to the faradaic reactions of NiS₂ nanocubes based on the surface redox mechanism of Ni²⁺ to Ni³⁺ at the surface. Further, NiS₂ nanocube electrodes possess a larger specific capacitance of 695 F g⁻¹ at a current density of 1.25 A g⁻¹ than that of NiS₂ nanospheres and nanoparticles.¹¹⁵

5.4. Molybdenum sulfide

Molybdenum disulfide (MoS₂) is one of the most considered van der Waals solids, which has unique physical properties when it is in single-layer, multi-layer, or re-stacked layer forms. These can be fabricated by chemical exfoliation from its layered 3D structure.^{104,135} In particular, the layered structure and inherent conductivity of MoS₂ have provoked interest among other transition metal sulfides. Therefore, it is considered to be a suitable replacement for graphene and carbon nanotubes in energy storage applications. Besides, Mo-based substances (such as MoO₃, MoO₂, and MoS₂) make them viable candidates for electrochemical applications due to their various valence states and rich chemical properties.^{136,137} Further, MoS₂ possesses unique atomic and electronic structure.¹⁰⁰ Moreover, MoS₂ have fourteen different polymorphs with varying electrical and optical properties of interest. A recent simulation-based research shows that the seven out of fourteen polymorphs are both dynamically and mechanically stable, which make them interesting candidates for optoelectronic applications.¹³⁸ MoS₂ continues to attract much attention, particularly in supercapacitors due to its higher intrinsic fast ionic conductivity (than oxides) and higher capacity (than graphite).¹³⁹⁻¹⁴²



Hu *et al.*, Balasingam *et al.*, Kanaujiya *et al.*, and Luo *et al.* synthesized MoS₂ nanostructures as electrodes for capacitor applications. Hu *et al.* synthesized porous tubular C/MoS₂ nanocomposite on Ni foam by the hydrothermal method. The CV curve of the nanocomposite electrode exhibits a remarkable reversible redox peak, which suggests the pseudocapacitive properties of the nanocomposite. The GCD parameters display the specific capacitance of 210 F g⁻¹ at the current density of 1 A g⁻¹ for the C/MoS₂ nanocomposite, which is higher than that of pure CNTs.⁹⁶ The double-layer capacitive performance of the MoS₂ nanostructures in 1.0 M Na₂SO₄ electrolyte solution with the potential window of -0.8 to 0.2 V at the scanning rate of 10 mV s⁻¹ was reported by Huang *et al.*, as shown in Fig. 30a. The GCD curve of the MoS₂ nanosheets electrode is shown in Fig. 30b with the highest specific capacitance of 129.2 F g⁻¹ at a current density of 1.0 A g⁻¹.⁹⁷ Further, the specific capacitances of 90.1, 225, and 218.4 F g⁻¹ at the current density of 1 A g⁻¹ have been reported for sponge-like MoS₂, flower-like mesoporous MoS₂, and irregular MoS₂ nanosheet, respectively.¹⁰¹⁻¹⁰³

Wang *et al.* synthesized 3D flower-like MoS₂ electrode materials through the hydrothermal method by varying the duration of treatment in the autoclave. The calculated specific capacitances revealed that the MoS₂-16 electrode (treatment time 16 h) had a higher specific capacitance of 518.7 F g⁻¹ at a current density of 1 A g⁻¹ than those of MoS₂-8 (treatment time 8 h) and MoS₂-24 (treatment time 24 h) electrodes. This higher specific capacitance of the 3D flower-like MoS₂-16 is partially attributed to its ultrathin and porous features, which can facilitate richer electroactive sites and more efficient electron transport.⁹⁹ Moreover, Yu *et al.* synthesized MoS₂ nanosheets on TiN nanorods (TMS). The CV parameters of the above material revealed that even though TiN significantly contributed to the capacitance, the major contributor was MoS₂. The maximum specific capacitance of the TMS-6 electrode (reaction time 6 h) resulted in about 662.2 mF cm⁻² at the current density of 1 mA cm⁻². It was 4.5 times and 4.9 times higher than that of the pristine MoS₂ electrode and TiN electrode, respectively. This is a clear evidence for the presence of synergistic effect in the MoS₂-TiN composite.¹⁰⁰

Yang *et al.* synthesized edge-oriented MoS₂ thin-film by electrodeposition method and its measured cyclic voltammogram shows quasi-rectangular shapes with a pair of small humps due to the cation intercalation and reversible redox reactions between the valence states of Mo⁴⁺ and Mo³⁺. The

specific capacitance of edge-oriented MoS₂ thin film is 12.5 mF cm⁻² at the scan rate of 50 mV s⁻¹.¹⁰⁴

5.5. Tin sulfide

Tin (Sn)-formulated sulfides, such as tin monosulfide (SnS) and tin disulfide (SnS₂), may be designated as multifunctional materials due to their potential applications.¹⁴³ In the compound semiconductors, the IV-VI group binary compound SnS and SnS₂ has received much attention as a potential candidate due to its remarkable stability, optical properties, and structural characteristics.¹⁴⁴⁻¹⁴⁹ Further, SnS is increasingly being investigated as a photoconverter because it is neither toxic nor expensive, and its commercial availability.¹⁵⁰⁻¹⁵² Furthermore, it is a layered semiconductor and possesses an orthorhombic crystal structure. Besides, SnS₂ possesses a layered structure, similar to CdI₂, in which the tin atoms are located between two hexagonally close-packed sulfur slabs to form a three-atom sandwich structure.¹⁵³⁻¹⁶⁰

Patil *et al.* deposited the SnS thin films by chemical bath deposition at different deposition times of 120, 240, and 360 min denoted as TS1, TS2, and TS3, respectively. The CV measurements were carried out in a 2 M KOH electrolyte solution for bare SS substrate (stainless steel), TS1, TS2, and TS3 electrodes with a potential range of -0.5 to -1.2 V. The rectangular-shaped CV curves with small redox peaks show that the charge storage is due to redox reactions as well as EDLC-type reactions. The specific capacitance values of TS1, TS2, and TS3 electrodes are found to be 950, 1203, and 1055 F g⁻¹, respectively, at a scan rate of 5 mV s⁻¹. The measured specific capacitance values varied due to the variation in the morphologies of the SnS films at different deposition times. The nanoflower-like morphology of SnS offers a more specific surface area for fast charge intercalation/de-intercalation reactions.⁹⁵

Moreover, a leaf-like SnS₂ nanosheet was synthesized using hydrothermal method by Ma *et al.* Fig. 31a shows the CV curves of bare nickel foam, bare SnS₂ nanosheets, and m-SnS₂ hierarchical architectures in the potential range from -0.1 to 0.4 V at the scan rate of 10 mV s⁻¹ in KOH solution. The CV curves of all the electrodes confirm that they are distinct from the ideal rectangular curve originating from the electric double-layer capacitor.^{3,161} All the electrodes with redox peaks indicate the reversibility of the redox processes, which results from the intercalation of K⁺ ions into the S-Mo-S layer.^{162,163} Moreover, it can be seen that the m-SnS₂ electrode possesses a higher specific capacitance than that of the bare SnS₂ electrode and nickel foam. The GCD curves of bare SnS₂ nanosheets and m-SnS₂ architectures are shown in Fig. 31b and c, respectively. The specific capacitance values of bare SnS₂ and m-SnS₂ at a current density of 1 A g⁻¹ are calculated to be 89.4 and 213.2 F g⁻¹, respectively.⁹³

5.6. Cobalt sulfide

Cobalt sulfide is an important member of TMS and a potential candidate for energy storage applications.¹⁶⁴ It possesses potential supercapacitor applications due to its several

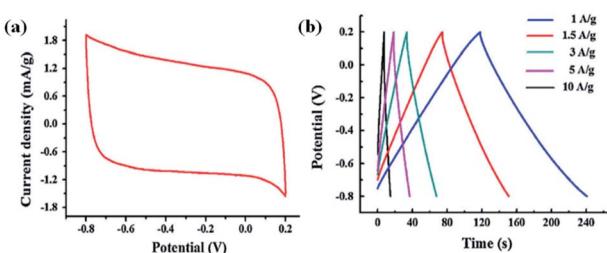


Fig. 30 (a) CV curve and (b) GCD curve of MoS₂ nanosheets.⁹⁷



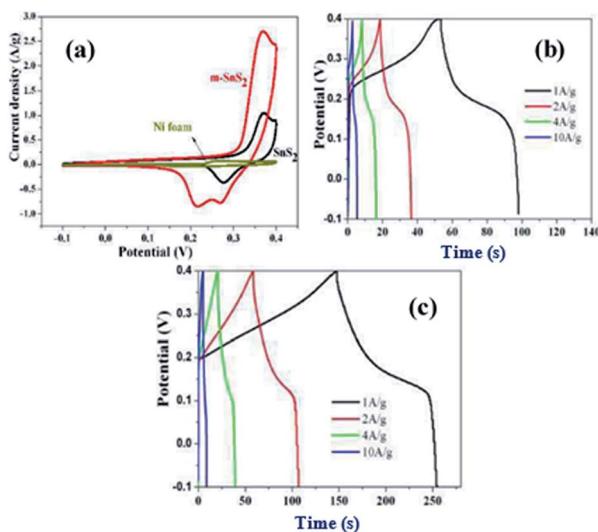


Fig. 31 (a) CV curves of bare nickel foam, bare SnS₂ nanosheets, and m-SnS₂ architectures, and GCD curves of (b) bare SnS₂ nanosheets and (c) m-SnS₂ architectures.⁹³

advantages such as low cost, electrical activity, long-term stability, as well as excellent electronic and physicochemical properties.^{165–168} Further, it possesses a variety of phases such as CoS, CoS₂, Co₂S₃, Co₃S₄, Co₉S₈, and Co_{1-x}S, which depends on the ratio of cobalt to sulfur.¹⁶⁹ The electrochemical performance is enriched by the high redox activity of cobalt sulfide.^{170,171} CoS has received special attention due to its rich redox couples (Co²⁺/Co³⁺ and Co³⁺/Co⁴⁺), different morphologies, and ultra-high capacitance value.¹⁷²

Several methods, such as solvothermal, CBD, ED, MWA, hot injection, and hydrothermal methods, have been used to synthesize cobalt sulfide nanostructures with a variety of phases. Li *et al.* have developed an ultralong CoS_{1.097} nanotube network assembled by interlaced nanoflakes using a simple one-step solvothermal method. Two pairs of redox peaks were observed in the CV curve of CoS_{1.097} in 2 M aqueous KOH electrolyte, indicating the coexistence of an electric double-layer capacitance and pseudocapacitive behavior. The specific capacitance values of CoS_{1.097}, calculated from the corresponding GCD curves, were found to be approximately 764, 686, 597, 400, and 237 F g⁻¹ at the current densities of 0.5, 1, 2, 5, and 10 A g⁻¹ respectively. Besides, Li *et al.* prepared 3D flower-like Co_{1-x}S by varying the amount of the precursor of the sulfur source and its CV curve illustrates the faradaic behavior of the Co_{1-x}S electrode material, which contributes to the electron transfer process of the Co²⁺/Co³⁺ redox couple. The specific capacitances of the two flower-like structures of Co_{1-x}S, synthesized in diethanolamine (DEA) and calculated from their discharge curves, are 674 and 600 F g⁻¹, respectively. These values are higher than that of the nanospheres of CoS₂ (360 F g⁻¹) synthesized in pure water at a current density of 3 A g⁻¹.⁷²

Peng *et al.* prepared CoS₂ hollow sphere electrodes that exhibit high pseudocapacitances of 1301, 1073, 883, 650, and 450 F g⁻¹ at current densities of 1, 2.5, 5, 10, and 20 A g⁻¹, respectively. The highest specific capacitance of hollow sphere

CoS₂ sample was further confirmed by carrying out comparative studies with bulk CoS₂ and other CoS₂ spheres (double-shell and yolk-shell). The ultrathin nanosheets build mesoporous spheres that facilitate high surface area and several electroactive sites for redox reaction, which encourage the pseudocapacitive performance of the CoS₂ hollow sphere.^{92,172} Furthermore, Tang *et al.*⁷⁴ synthesized CoS₂-rGO nanocomposite and its CV measurements were taken in 6 M KOH electrolyte solution. The CV curves shown in Fig. 32a and b reveal the typical pseudocapacitive behavior of the CoS₂ and CoS₂-rGO electrodes. The CoS₂-rGO nanocomposite exhibits a specific capacitance value of 265 F g⁻¹, which is higher than that of CoS₂ (135 F g⁻¹). This could be attributed to the synergistic effect of CoS₂ and reduced graphene oxide, and the good conductivity of CoS₂ nanoparticles might have prevented the agglomeration of CoS₂.

The preparation of CoS nanostructures on nickel foam by the CBD method has been reported by Anil Kumar *et al.* CV measurements of these nanostructures were carried out in 1 M KOH electrolyte with a potential window between 0.4 and 0.6 V at the scan rate of 30 mV s⁻¹. The CV curve of the ethanol-based CoS electrode showed a pair of well-defined redox peaks as a result of the reversible faradaic reaction. The pseudocapacitance behavior of this electrode was higher when compared to water-based and water/ethanol-based CoS electrodes owing to the resultant large pore size, reduced surface area, and poor adhesion to the substrate.^{169,173,174} Further, the use of water and water/ethanol system led to less interaction between the KOH electrolyte and the electrode.^{51,175} The specific capacitances of 31.66, 41.36, and 21.7 F g⁻¹ at the current density of 1.5 A g⁻¹ were observed for the CoS electrodes prepared using water, ethanol, and water/ethanol system, respectively.⁵⁰

Gervas *et al.* demonstrated the GCD non-linear curves of CoS-1 (200 °C) and CoS-2 (260 °C), which were synthesized by the hot injection method. It shows typical pseudocapacitance behavior attributed to faradaic redox reactions at the CoS sample surface. A larger charge storage capacity was obtained by the longer charge and discharge time for CoS-2 than CoS-1 at the same current density. The maximum specific capacitances for CoS-2 samples were found to be 440 and 1059 F g⁻¹ as calculated from the GCD (current density of 1 A g⁻¹) and CV (scan rate of 1 mV s⁻¹) curves, respectively. From these results, it was concluded that cobalt sulfide with a lower deficiency of sulfur might be better for electrochemical applications.⁹⁰

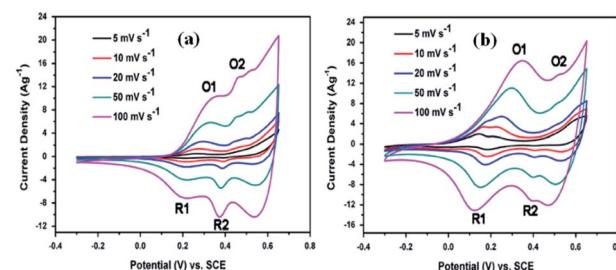


Fig. 32 CV curves of (a) CoS₂ and (b) CoS₂-rGO in 6 M KOH electrolyte.⁷⁴

5.7. Quantitative electrochemical performance

In this comprehensive review, the electrochemical energy storage ability of several transition and post-transition metal sulfides along with their usage as electrode materials in supercapacitors and pseudocapacitors have been discussed. The best quantitative electrochemical performance of each

transition and post-transition metal sulfide electrode material is summarized in Table 2.

Here, recent studies reported on transition and post-transition metal sulfide-based capacitors were reviewed. Different structural characteristics and the capacitive nature of particular transition and post-transition metal sulfides, which are widely used in this area, such as Bi_2S_3 , CuS , MoS_2 , NiS_2 , NiS ,

Table 2 The specific capacitance of each transition and post-transition metal sulfide electrode material

| Material | Method of synthesis | Specific capacitance | Conditions | Ref. |
|--|------------------------|----------------------------|--|-----------|
| Bi_2S_3 | ST | 632.0 F g^{-1} | Current density of 0.5 A g^{-1} | 59 |
| Bi_2S_3 -rGO | HT | 396.0 F g^{-1} | Current density of 1 A g^{-1} | 60 |
| CuS | ST | 833.3 F g^{-1} | Current density of 1 A g^{-1} | 63 |
| $\text{CuS}/\text{MWCNT}/\text{Ni}$ foam | HT | 2831.0 F g^{-1} | Current density of 1 A g^{-1} | 66 |
| CuS/Ni foam | HT | 1124.0 F g^{-1} | Current density of 15 A g^{-1} | 68 |
| CuS/FTO thin films | HT | 8.3 mF cm^{-2} | Current density of 1 mA cm^{-2} | 69 |
| CuS/CCs | HT | 1025.0 mF cm^{-2} | Current density of 2 mA cm^{-2} | 70 |
| Co_{1-x}S | ST | 674.0 F g^{-1} | Current density of 3 A g^{-1} | 71 |
| $\text{CoS}_{1.097}$ | ST | 686.0 F g^{-1} | Current density of 1 A g^{-1} | 72 |
| CoS_2 | ST | 1301.0 F g^{-1} | Current density of 1 A g^{-1} | 73 |
| CoS_2 -rGO | ST | 331.0 F g^{-1} | Current density of 0.5 A g^{-1} | 74 |
| CoS | ST | 156.0 F g^{-1} | Current density of 1 A g^{-1} | 88 |
| CoS_2 | HT | 499.0 F g^{-1} | Current density of 1 A g^{-1} | 75 |
| rGONF/CoS ₂ | HT | 635.8 F g^{-1} | Current density of 1 A g^{-1} | 76 |
| CCs/CoS ₂ | HT | 322.0 F g^{-1} | Current density of 0.5 A g^{-1} | 77 and 78 |
| | | 245.0 F g^{-1} | Current density of 1 A g^{-1} | |
| $\text{CoS}_2/\text{MWCNT}$ | HT | 1846.0 F g^{-1} | Current density of 1 A g^{-1} | 79 |
| $\text{Co}_9\text{S}_8/3\text{DG}$ | HT | 1366.0 F g^{-1} | Current density of 1 A g^{-1} | 80 |
| Activated $\text{Co}_9\text{S}_8/3\text{DG}$ | | 2317.0 F g^{-1} | Current density of 1 A g^{-1} | |
| $\text{Co}_3\text{S}_4/\text{rGO}$ | HT | 2314.0 F g^{-1} | Scan rate of 2 mV s^{-1} | 81 |
| $\text{Co}_3\text{S}_4/\text{NF}$ | HT | 2415.0 F g^{-1} | Current density of 1 A g^{-1} | 82 |
| CoS | HT | 285.0 F g^{-1} | Current density of 0.5 A g^{-1} | 83 |
| | | 245.0 F g^{-1} | Current density of 1 A g^{-1} | |
| CoS | | 932.0 F g^{-1} | Current density of 5 A g^{-1} | 84 |
| CoS/NF | ED | 1471.0 F g^{-1} | Current density of 4 A g^{-1} | 85 |
| $\text{CoS}/\text{eRG}/\text{Ni}$ foam | ED | 3785.0 F g^{-1} | Current density of 1 A g^{-1} | 86 |
| CoS/NF | CBD | 41.3 F g^{-1} | Current density of 1.5 A g^{-1} | 50 |
| CoS/NF | MWA | 586.0 F g^{-1} | Current density of 1 A g^{-1} | 87 |
| CoS | MWA | 224.0 F g^{-1} | Current density of 1 A g^{-1} | 88 |
| CoS_x | Wet chemical synthesis | 475.0 F g^{-1} | Current density of 5 mA cm^{-2} | 89 |
| CoS | Hot injection method | 440.0 F g^{-1} | Current density of 1 A g^{-1} | 90 |
| CdS/Ni foam | HT | 909.0 F g^{-1} | Current density of 0.6 A g^{-1} | 91 |
| γ -MnS/rGO/carbon paper | HT | 547.6 F g^{-1} | Current density of 1 A g^{-1} | 92 |
| m-SnS ₂ | HT | 213.2 F g^{-1} | Current density of 1 A g^{-1} | 93 |
| O-SnS | CBD | 1101.0 F g^{-1} | Current density of 1 mA cm^{-2} | 94 and 95 |
| C/MoS ₂ | HT | 210.0 F g^{-1} | Current density of 1 A g^{-1} | 96 |
| MoS ₂ | HT | 129.2 F g^{-1} | Current density of 1 A g^{-1} | 97 |
| MoS ₂ | HT | 92.5 F g^{-1} | Current density of 0.5 mA cm^{-2} | 98 |
| MoS ₂ | HT | 518.7 F g^{-1} | Current density of 1 A g^{-1} | 99 |
| MoS ₂ film | HT | 218.4 F g^{-1} | Current density of 1 A g^{-1} | 103 |
| MoS ₂ /Mo foil | ED followed by CVD | 14.5 mF cm^{-2} | Current density of 1 mA cm^{-2} | 104 |
| Ni ₃ S ₂ | HT | 1370.4 F g^{-1} | Current density of 2 A g^{-1} | 105 |
| Ni ₃ S ₂ /NF | HT | 694.0 F g^{-1} | Current density of 20 mA cm^{-2} | 106 |
| Ni ₃ S ₂ /NF | HT | 710.4 F g^{-1} | Current density of 2 A g^{-1} | 107 |
| CNT@Ni ₃ S ₂ | HT | 514.0 F g^{-1} | Current density of 4 A g^{-1} | 108 |
| NiS/C-dot | HT | 880.0 F g^{-1} | Current density of 2 A g^{-1} | 109 |
| α -NiS | HT | 562.3 F g^{-1} | Current density of 0.6 A g^{-1} | 110 |
| β -NiS | HT | 501.5 F g^{-1} | Current density of 0.6 A g^{-1} | 110 |
| NiS/Ni foam | HT | 2384.0 F g^{-1} | Current density of 1 A g^{-1} | 111 |
| Ni ₃ S ₂ /NF | ED | 717.0 F g^{-1} | Current density of 2 A g^{-1} | 112 |
| Nickel sulfide/ERGO | ED | 1392.2 F g^{-1} | Current density of 2 A g^{-1} | 113 |
| NiS/Ti foil | CBD | 788.0 F g^{-1} | Current density of 1 mA cm^{-2} | 114 |
| NiS ₂ /NF | MWA | 695.0 F g^{-1} | Current density of 1.25 A g^{-1} | 115 |



Ni_3S_2 , CoS , CoS_2 , SnS , and SnS_2 have been focused. The controlled morphologies, ability for the formation of different phases, high symmetry in their crystal forms, and enhanced electrical conductivity of the above materials have highly attracted the researchers to expand the applications of these materials. Even though significant advancement has been made in this promising research field, an intensive study is crucial to produce commercially viable applications. In this regard, various transition and post-transition metal sulfides with nanostructured morphologies and increased active surface have been produced by facile synthetic methods in the past decade, which exhibited enhanced capacitance *via* the improved rate of electron transfer and higher penetration of the electrolyte. Herein, we have discussed the individual electrochemical performance of reviewed transition and post-transition metal sulfides according to the ascending order of the reported highest specific capacitance values.

Nanosheets, sphere-like nanostructures, 3D flower-like microspheres composed of nanosheets, sponge-like nanostructures, and flower-like mesoporous structures of hydrothermally prepared MoS_2 were reviewed in this study. Among them, 3D flower-like microspheres composed of nanosheets of MoS_2 showed a high specific capacitance of 518.7 F g^{-1} at a current density of 1 A g^{-1} . Further, autoclaved time and temperature of synthesis played a crucial role in the resultant morphologies of MoS_2 . Furthermore, in addition to hydrothermal preparation, ED followed by CVD methods of MoS_2 preparation was also reported.

Further, $\gamma\text{-MnS}/\text{rGO}$ -coated carbon paper showed a specific capacitance of 547.6 F g^{-1} at a current density of 1 A g^{-1} . An improved electronic conductivity confines aggregation and the lessening of the volume variation of $\gamma\text{-MnS}$ resulted due to the presence of rGO wrapping on $\gamma\text{-MnS}$ nanorods.

The hydrothermally prepared $\text{Bi}_2\text{S}_3\text{-rGO}$ nanosheet composites with uniform morphology showed a specific capacitance of 396.0 F g^{-1} at a current density of 1 A g^{-1} , whereas solvothermally prepared sphere-like Bi_2S_3 nanoparticles showed high specific capacitance of 632.0 F g^{-1} at a current density of 0.5 A g^{-1} due to its high specific surface area and facilitated electrochemically active sites for electron flow. Further, a good cycling stability was observed by a capacitance retention of 87% after 500 charge/discharge cycles.

Hydrothermally prepared CdS coated Ni foam resulted a specific capacitance of 909 F g^{-1} at a current density of 0.6 A g^{-1} . The fabricated supercapacitor showed excellent cycling stability over 5000 charge/discharge cycles at a current density as large as 14.2 A g^{-1} , and 104% of initial capacitance was maintained. However, the toxicity of CdS is of concern to find suitable alternative materials.

Hydrothermally prepared molybdenum-doped leaf-like SnS_2 showed higher specific capacitance of 213.2 F g^{-1} at a current density of 1 A g^{-1} compared to bare SnS_2 electrodes, whereas orthorhombic nanoflower-like SnS prepared by CBD showed a specific capacitance of 1101 F g^{-1} at a current density of 1 mA cm^{-2} . This could be attributed to nanoflower-like morphology of SnS , which facilitates a higher surface area for fast charge intercalation and de-intercalation reactions. Moreover, these

orthorhombic SnS nanoflowers-coated electrodes exhibit good electrochemical stability over 1000 cycles with capacitance retention of 90.2% at 100 mV s^{-1} .

Ni_3S_2 , NiS_2 and NiS phases of nickel sulfides are widely focused in this area. Among them, hollow nanoframe-like particles constructed with nanocubes of NiS showed high specific capacitance of 2384 F g^{-1} at a current density of 1 A g^{-1} than other phases including 3D nanosheets of Ni_3S_2 , nanoflakes of Ni_3S_2 , hollow spheres of NiS , hierarchical flower-like nanostructure of NiS , and nanocubes and nanospheres of NiS_2 . The hollow nature of nanoframe-like particles constructed with nanocubes of NiS provides high specific surface area, which facilitates efficient electron transport through good electrical conductivity and promotes electrolyte diffusion between the electrode and the electrolyte. Moreover, capacitance retention of 90.2% after 4000 cycles resulted at a current density of 4 A g^{-1} .

Hydrothermally prepared CuS -based electrode showed high electrochemical performance than solvothermally prepared CuS as hydrothermally prepared CuS coated on Ni form showed a specific capacitance of 1124.0 F g^{-1} at a current density of 15 A g^{-1} , which is higher compared to CuS coated on CCs. However, the MWCNTs blending with CuS , which was coated on Ni form, showed a high specific capacitance of 2831.0 F g^{-1} at a current density of 1 A g^{-1} due to the enhanced specific surface area and excellent conductivity of MWCNTs. Further, MWCNTs facilitate efficient charge transport and promote electrolyte diffusion; thus, the system has good cycling stability over 600 cycles with capacitance retention of more than 90%.

Generally, cobalt sulfide materials lack insufficient support for fast electron transport in faradaic redox reactions at high current density. The high performance of cobalt sulphide electrode was achieved by incorporating electrochemically reduced graphene (eRG). The connected graphene matrix, which is tightly wrapped with CoS , serves as an electronic super path to facilitate fast charge transfer during both charge and discharge processes. Further, this integrated structure led to enlarged electroactive surface area of the electrode materials. CoS/eRG exhibited an impressive high specific capacitance of 3785 F g^{-1} at a current density of 1 A g^{-1} with capacitance retention of 82% at 20 A g^{-1} .

6. Summary and perspectives

To produce high-performance supercapacitors with transition and post-transition metal sulfide-based electrodes, a further increase in the specific capacitance can be obtained by investigating the morphology, particle size, surface area, and conductivity of the electrode. Nanostructures of transition and post-transition metal sulfides with high specific surface area can facilitate efficient contact with electrodes and electrolyte ions, providing more electroactive sites for energy storage. For example, various nanostructured materials including 3D flower-like microspheres composed of nanosheets, spheres, nanoflowers, and hollow nanoframes have been reported as high-performance supercapacitor electrode materials. Further, a suitable nanomaterial can be integrated with metal sulfides to



overcome the drawbacks of conductivity of individual metal sulfides by providing versatile platforms for efficient charge transfer.

Due to their high electrochemical performances, Bi_2S_3 , CuS , MoS_2 , NiS_2 , NiS , Ni_3S_2 , CoS , CoS_2 , CdS , SnS , and SnS_2 are effective candidates as electrodes for supercapacitors, which can also be integrated with DSSC in order to build integrated solar/photo capacitors. However, in heterostructured photocapacitors, the capacitive nature is achieved by the oxidation of lower chemical state of sulfide materials into their higher chemical state by forming their oxides in the active photoelectrodes. For this purpose, CoS , NiS , Ni_3S_2 , SnS , PbS , and Bi_2S_3 are particularly the most potential candidates as active electrodes since their sulfides are in lower oxidation state. However, PbS should be avoided due to its toxicity. In recent times, self-powered photocapacitors have attracted much interest due to their free energy conversion from the sun and self-charging properties; thus, the growth of such photocapacitors may be beneficial to be used along with/or replace batteries in many smart electronic devices in the future. We hope that this comprehensive review on transition and post-transition metal sulfides in supercapacitors will encourage further research into the potential application of the same photocapacitors.

Author contributions

Conceptualization: K. T., D. V., M. S.; methodology: K. T., A. P., D. V., M. S.; formal analysis: K. T., A. P.; software: K. T., A. P.; investigation: K. T., A. P., D. V., M. S.; validation: K. T., A. P., D. V., M. S., P. R.; writing – original draft: K. T., A. P.; visualization: K. T., A. P., D. V., M. S.; writing – review & editing: K. T., A. P., A. Y., Y. S., M. S., D. V., P. R.; supervision: M. S., A. Y., D. V., P. R.; project administration: D. V., P. R.; funding acquisition: D. V., P. R.; all authors have read and agreed to the published version of the manuscript.

Conflicts of interest

There are no conflicts to declare.

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